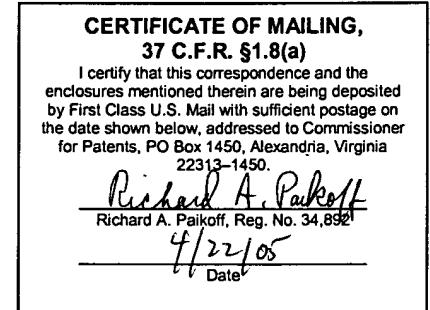


IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Wei-Yu Su
Application No.: 10/040,042
Filed : November 7, 2001
TC/A.U. : 1746
Title : Method for Reduction of Photomask Defects

Docket No. : N1085-90003
Customer No. : 08933

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450



RESPONSE TO NOTICE OF NON-COMPLIANT AMENDMENT

Sir:

The Notice of Non-Compliant Amendment (37 CFR 1.121) mailed April 13, 2005, states that the Amendment filed on April 6, 2004, was considered non-compliant due to improper claim status identifiers. Specifically, claim 7 was incorrectly identified as "presently amended" and should be changed to correctly read -currently amended--.

Attached is a complete listing of the claims as presented in said Amendment with the claim status identifier corrected, as required, for claim 7.

Respectfully submitted,

Date 4/22/05

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